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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO		
09/824,348	04/02/2001	Alexander J. Pasadyn	2000.058100	9339		
23720 7	590 06/10/2004		EXAM	EXAMINER		
WILLIAMS, MORGAN & AMERSON, P.C.			PRETLOW, DI	PRETLOW, DEMETRIUS R		
HOUSTON, T	OND, SUITE 1100 X 77042		ART UNIT	PAPER NUMBER		
,			2863			
			DATE MAILED: 06/10/2004	1		

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)			
Office Action Summary		09/824,348 PASADYN ET /				
		Examiner	Art Unit)		
		Demetrius R. Pretlow	2863	M		
Period fo	The MAILING DATE of this communication ap or Reply	pears on the cover sheet with	h the correspondence ad	dress		
THE - Exte after - If the - If NO - Failt Any	MORTENED STATUTORY PERIOD FOR REPL MAILING DATE OF THIS COMMUNICATION. ensions of time may be available under the provisions of 37 CFR 1. r SIX (6) MONTHS from the mailing date of this communication. e period for reply specified above is less than thirty (30) days, a rep O period for reply is specified above, the maximum statutory period ure to reply within the set or extended period for reply will, by statut reply received by the Office later than three months after the mailined patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a repoly within the statutory minimum of thirty a will apply and will expire SIX (6) MONT te, cause the application to become ABA	oly be timely filed (30) days will be considered timely HS from the mailing date of this co			
Status						
1)🛛	Responsive to communication(s) filed on <u>02 A</u>	<u> April 2001</u> .				
2a)[_	This action is FINAL . 2b)⊠ This action is non-final.					
3)						
	closed in accordance with the practice under	Ex parte Quayle, 1935 C.D.	11, 453 O.G. 213.			
Disposit	tion of Claims					
5)⊠ 6)□ 7)⊠	Claim(s) <u>1-7,9-30</u> is/are pending in the applicated 4a) Of the above claim(s) is/are withdray Claim(s) <u>3-5,14-16,30</u> is/are allowed. Claim(s) <u>1,2,6,7,9-13 and 17-23</u> is/are rejected Claim(s) <u>3,24,26,9-11</u> is/are objected to. Claim(s) are subject to restriction and/or	awn from consideration. ed.				
Applicat	tion Papers					
9)[The specification is objected to by the Examin	er.				
10)[The drawing(s) filed on is/are: a) acc	cepted or b) objected to b	y the Examiner.			
	Applicant may not request that any objection to the					
11)	Replacement drawing sheet(s) including the correct The oath or declaration is objected to by the E					
		.xamiller. Note the attached	Office Action of formation	0-132.		
-	under 35 U.S.C. § 119					
	Acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority document Certified copies of the priority document Copies of the certified copies of the priority document Copies of the certified copies of the priority document Copies of the certified copies of the priority document Copies of the certified copies of the priority document Copies of the certified copies of the priority document Copies of the priority document Copies of the certified copies of the priority document Copies of the priority document Copies of the certified copies of the priority document Copies of the	nts have been received. nts have been received in Ap ority documents have been r	plication No	Stage		
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Attachmer 1) Notice	nt(s) ce of References Cited (PTO-892)	4) 🔲 Interview Su	ımmary (PTO-413)			
2)	ce of Draftsperson's Patent Drawing Review (PTO-948) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/08 er No(s)/Mail Date	Paper No(s)	/Mail Date formal Patent Application (PTC	D-152)		

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DETAILED ACTION

Claim Objections

Claims 5,24, 26 and 9-11 are objected to because of the following informalities:
 It appears that claims 9-11 should depend from claim 1 or 3. Appropriate correction is required.

In claim 5, line 1, it appears that --4—should be changed to --3--.

In claim 24, line 1, it appears that --2—should be changed to -1--.

In claim 26, line 1, it appears that -25-- should be changed to -1--.

Claim Rejections - 35 USC § 102

- 1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:
 - A person shall be entitled to a patent unless -
 - (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claim 19 rejected under 35 U.S.C. 102(e) as being anticpated by Nicholson.

Nicholson teach a plurality of tools for processing manufactured items in a process flow. Note Nicholson et al. column 2, lines 56-60. Nicholson teach a database (118) adapted to store a set of production environment data associated with each of the manufactured items. Note Nicholson et al. column 2, lines 56-61. Nicholson teach a drift

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monitor (100) to identify manufactured items associated with a process drift. Note Nicholson column 6, lines 4-7. Nicholson teach a plurality of characteristic threads based on the production environment data. Nicholson does not explicitly teach generate however that would be inherent to the invention of Nicholson. Note Nicholson column 3, lines 8-35. Nicholson teach a weight value is assigned to each lot in the lot list.

Typically, the wafer lots without the failure signature are assigned negative weight values, such as -1, and the wafer lots having the failure signature are assigned positive weight values, which suggests comparing the characteristic threads for at least those manufactures items associated with the process drift. Note Nicholson column 4, lines 7-23. Nicholson teach determining at least one potential cause for the process drift based on the comparison of the characteristic threads. Note Nicholson column 4, lines 24-40.

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 1,2,6,7,9-13,17,18,20-23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nicholson (US 6,580,960) in view of Milor et al. Nicholson teach processing s plurality of manufactured items in a process flow. Note Nicholson column 2, lines 37-44. Nicholson teach storing a set of production environment data associated with each of the manufactured items. Note

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Nicholson column 2, lines 56-60. Nicholson teach identifying manufactured items associated with a process drift. Note Nicholson column 6, lines 4-7. Nicholson teach a plurality of characteristic threads based on the production environment data. Nicholson does not explicitly teach the step of generating however this step would be inherent to the process of Nicholson. Note Nicholson column 3, lines 8-35. Nicholson teach a weight value is assigned to each lot in the lot list. Typically, the wafer lots without the failure signature are assigned negative weight values, such as -1, and the wafer lots having the failure signature are assigned positive weight values, which suggests comparing the characteristic threads for at least those manufactures items associated with the process drift. Note Nicholson column 4, lines 7-23. Nicholson teach determining at least one potential cause for the process drift based on the comparison of the characteristic threads. Note

Nicholson does not teach at least one of the characteristic threads being associated with other than processing tools used in the process flow.

Milor et al. teach at least one of the characteristic threads being associated with other than processing tools used in the process flow. Note Milor et al. column 5, lines 8-25.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to modify the invention of Nicholson to include the teaching of Milor et al. because it would allow diagnosing defects that impact the topography of an integrated circuit wafer surface. Note Milor et al. column 2, lines 33-35.

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categories.

In reference to claim 2, Nicholson teach all of the limitations above.

Nicholson does not teach grouping the characteristic threads into characteristic

Milor et al. teach grouping the characteristic threads into characteristic categories. Note Milor et al. column 2, lines 48-62.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to modify the invention of Nicholson in view of Milor et al. because it would allow the number of feasible defect causes to be narrowed down. Note Milor et al. column 2, lines 40-44.

In reference to claim 23, Nicholson teach means for processing a plurality of manufactured items in a process flow. Note Nicholson column 2, lines 45-51. Means for storing a set of production environment data (118) associated with each of the manufactured items. Note Nicholson column 2, lines 56-60. Nicholson teach means for identifying manufactures items associated with the process drift. Note Nicholson claim 6, lines 5-9. Nicholson teach a plurality of characteristic threads based on the production environment data. Nicholson does not explicitly teach generate, however that would be inherent to the invention of Nicholson. Note Nicholson column 3, lines 8-35. Nicholson teach a weight value is assigned to each lot in the lot list. Typically, the wafer lots without the failure signature are assigned negative weight values, such as -1, and the wafer lots having the failure signature are assigned positive weight values, which suggests comparing the characteristic threads for at least those manufactures items associated with the process drift. Note Nicholson column 4, lines 7-23. Nicholson

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teach means for determining at least one potential cause for the process drift based on the comparison of the characteristic threads. Note Nicholson column 4, lines 24-40.

Nicholson does not teach at least one of the characteristic threads being associated with other than processing tools used in the process flow.

Milor et al. teach at least one of the characteristic threads being associated with other than processing tools used in the process flow. Note Milor et al. column 5, lines 8-25.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to modify the invention of Nicholson to include the teaching of Milor et al. because it would allow diagnosing defects that impact the topography of an integrated circuit wafer surface. Note Milor et al. column 2, lines 33-35.

In reference to claim 6, Nicholson teach processing the plurality of manufactured items in the process flow comprises processing a plurality of semiconductor wafers in a semiconductor device during manufacturing process flow. Note Nicholson column 2, lines 45-47.

In reference to claim 7 Nicholson teach processing the plurality of semiconductor wafers into lots of wafers, an identifying the manufactured associated with the process drift comprises identifying particular lots of wafers associated with the process drift. Note Nicholson column 4, lines 7-24.

In reference to claim 9, Nicholson teach generating characteristic threads for metrology tools used to measure characteristics of semiconductor wafers in the process flow. Note column 2, lines 63-67 and column 3, lines 1-7.

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In reference to claim 10, Nicholas does not teach generating characteristic threads based on incoming characteristics of semiconductor wafers in the process flow.

Milor et al. teach generating characteristic threads based on incoming characteristics of semiconductor wafers in the process flow. Note column 4, lines 37-48.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to modify the invention of Nicholson to include the teaching of Milor et al. because it would allow diagnosing defects that impact the topography of an integrated circuit wafer surface. Note Milor et al. column 2, lines 33-35.

In reference to claim 11, Nicholas does not teach generating characteristic threads based on operating recipe parameters used for processing semiconductor wafers in the process flow.

Milor et al. teach generating characteristic threads based on operating recipe parameters used for processing semiconductor wafers in the process flow. Note Milor column 4, lines 37-48.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to modify the invention of Nicholson to include the teaching of Milor et al. because it would allow diagnosing defects that impact the topography of an integrated circuit wafer surface. Note Milor et al. column 2, lines 33-35.

In reference to claim 12, Nicholson teach a plurality of tools for processing manufactured items in a process flow. Note Nicholson et al. column 2, lines 56-60.

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Nicholson teach a database (118) adapted to store a set of production environment data associated with each of the manufactured items. Note Nicholson et al. column 2, lines 56-61. Nicholson teach a drift monitor (100) to identify manufactured items associated with a process drift. Note Nicholson column 6, lines 4-7. Nicholson teach a plurality of characteristic threads based on the production environment data. Nicholson does not explicitly teach generate however that would be inherent to the invention of Nicholson. Note Nicholson column 3, lines 8-35. Nicholson teach a weight value is assigned to each lot in the lot list. Typically, the wafer lots without the failure signature are assigned negative weight values, such as -1, and the wafer lots having the failure signature are assigned positive weight values, which suggests comparing the characteristic threads for at least those manufactures items associated with the process drift. Note Nicholson column 4, lines 7-23. Nicholson teach determining at least one potential cause for the process drift based on the comparison of the characteristic threads. Note Nicholson column 4, lines 24-40.

Nicholson does not teach at least one characteristic threads being associated with other than the processing tools in the process flow.

Milor et al. teach at least one of the characteristic threads being associated with other than processing tools used in the process flow. Note Milor et al. column 5, lines 8-25.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to modify the invention of Nicholson to include the teaching of Milor

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et al. because it would allow diagnosing defects that impact the topography of an integrated circuit wafer surface. Note Milor et al. column 2, lines 33-35.

In reference to claim 13, Nicholson teach grouping the characteristic threads into characteristic categories. Note column 4, lines 17-35.

In reference to claim 17, Nicholson teach semiconductor wafers processed in a semiconductor device manufacturing process flow. Note Nicholson column 2, lines 46-48.

In reference to claim 18, Nicholson teach the semiconductor wafers are grouped into lots of wafers, and the drift monitor is adapted to and identify particular lots of wafers associated withy the process drift. Note Nicholson column 2, lines 33-37.

In reference to claim 20, Nicholson teach generating characteristic threads for metrology tools used to measure characteristics of semiconductor wafers in the process flow. Note column 2, lines 63-67 and column 3, lines 1-7.

In reference to claim 21, Nicholas does not teach generating characteristic threads based on incoming characteristics of semiconductor wafers in the process flow.

Milor et al. teach generating characteristic threads based on incoming characteristics of semiconductor wafers in the process flow. Note column 4, lines 37-48.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to modify the invention of Nicholson to include the teaching of Milor et al. because it would allow diagnosing defects that impact the topography of an integrated circuit wafer surface. Note Milor et al. column 2, lines 33-35.

In reference to claim 22, Nicholas does not teach generating characteristic threads based on operating recipe parameters used for processing semiconductor wafers in the process flow.

Milor et al. teach generating characteristic threads based on operating recipe parameters used for processing semiconductor wafers in the process flow. Note Milor column 4, lines 37-48.

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to modify the invention of Nicholson to include the teaching of Milor et al. because it would allow diagnosing defects that impact the topography of an integrated circuit wafer surface. Note Milor et al. column 2, lines 33-35.

Allowable Subject Matter

Claims 24-29 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Claims 3-5,14-16,30 allowed.

Response to Arguments

Applicant's arguments with respect to claims 1,12,23 have been considered but are moot in view of the new ground(s) of rejection. Applicant argues that the previous cited art does not teach at least one characteristic threads being associated with other

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than processing tools used in the process flow. Milor is cited for teaching at least one characteristic threads being associated with other than processing tools used in the process flow. Note rejection above.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Demetrius R. Pretlow whose telephone number is (703) 272-2278. The examiner can normally be reached on 8-4:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, John Barlow can be reached on (703) 272-2269. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Demetrius R. Pretlow

Patent Examiner

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MICHAEL NGHIEM

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